

The Molecular Structures of Difluorophosphino(disilyl)amine and Bis(difluorophosphino)silylamine in the Gas Phase, determined by Electron Diffraction

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The molecular structures of difluorophosphino(disilyl)amine and bis(difluorophosphino)silylamine in the gas phase have been determined by electron diffraction. Both molecules have planar co-ordination at nitrogen, and Si-N bonds that are substantially longer than those in other silylamines. Principal bonds and angles (r_a) for $N(PF_2)(SiH_3)_2$ are $r(P-F)$ 158.5(3), $r(P-N)$ 168.0(4), $r(Si-N)$ 175.5(4) pm; FPF 96.9(10), FPN 99.4(7), and SiNSi 119.3(17)°. For $N(PF_2)_2(SiH_3)$ principal parameters are $r(P-F)$ 157.0(2), $r(P-N)$ 169.1(4), $r(Si-N)$ 176.7(7) pm; FPF 96.1(5), FPN 99.3(3), and PNP 117.6(7)°. In each compound the conformation adopted by the difluorophosphino-groups is such that the axes of the nitrogen and phosphorus lone-pair orbitals are approximately orthogonal.

THE molecular geometries of silicon- and phosphorus-substituted amines have been extensively studied. Trisilylamine^{1,2} is the most widely known inorganic compound with planar co-ordination at nitrogen, and the wide SiNSi angle in disilylamine³ suggests that the three bonds to nitrogen are coplanar. Similarly, the tertiary difluorophosphinoamine, $N(PF_2)_3$, has a planar NP_3 skeleton,⁴ and the secondary amine has a wide PNP angle.^{5,6} The planarity of the nitrogen in the primary amine, $NH_2(PF_2)$, is not so definitely established: a microwave study⁷ suggests that the PNH_2 group is planar, whereas limited information from an electron-diffraction study favours a non-planar arrangement.⁸ This apparent anomaly may arise from a low-frequency out-of-phase deformation, which would give a large shrinkage effect,⁹ and similar low-frequency modes may account for the apparent non-planarity of the NC_2Si and NC_2P skeletons of $NMe_2(PF_2)$ ⁸ and $NMe_2(SiH_3)$.¹⁰

However, of the three amines containing both silyl and difluorophosphino-substituents, only one, $NH(PF_2)(SiH_3)$, has been the subject of a structural study.¹¹ It was therefore important to study the other two,

EXPERIMENTAL

Samples of difluorophosphino(disilyl)amine and bis(difluorophosphino)silylamine were prepared by literature methods¹² and purified by fractional condensation *in vacuo*: purities were checked spectroscopically.

Electron-diffraction scattering intensities were recorded using the Cornell-Edinburgh diffraction apparatus,^{5,13} with nozzle-to-plate distances of 128 and 285 mm, and an accelerating voltage of *ca.* 43 kV. During exposure samples were maintained at 250 K, and the nozzle at room temperature, 293 K. Data were recorded on Kodak Electron Image plates, and obtained in digital form using a Jarrell-Ash double-beam microphotometer, with spinning plates.¹⁴ The electron wavelengths were determined from the scattering patterns of gaseous benzene, recorded immediately before or after the sample plates.

All calculations were carried out on an ICL 2970 computer at the Edinburgh Regional Computing Centre, using established data reduction⁵ and least-squares refinement programs.¹⁵ Weighting points used in setting up the off-diagonal weight matrices are given, together with other experimental data, in Table 1. In all calculations the complex scattering factors of Schäfer *et al.*¹⁶ were used.

Refinement.—*Difluorophosphino(disilyl)amine.* In refine-

TABLE I
Weighting functions, correlation parameters, and scale factors

Compound	Camera height/mm	Wavelength/ pm	$\Delta s/nm^{-1}$	s_{min}/nm^{-1}	sw_1/nm^{-1}	sw_2/nm^{-1}	s_{max}/nm^{-1}	p/h	Scale factor
$N(PF_2)(SiH_3)_2$	128.5	5.799	4	60	80	230	260	0.146	0.806(14)
	284.3	5.799	2	26	40	120	144	0.469	0.727(13)
$N(PF_2)_2(SiH_3)$	128.4	5.854	4	64	80	240	316	0.348	0.960(18)
	285.6	5.854	2	26	30	120	142	0.446	0.900(13)

$N(PF_2)_2(SiH_3)$ and $N(PF_2)(SiH_3)_2$, as these would be expected to have planar arrangements of the bonds to nitrogen. It was also of interest to see whether there was any evidence of competition between phosphorus and silicon for the nitrogen lone pair of electrons, leading to a shortening of one type of bond to nitrogen at the expense of the other type. Finally, the conformations adopted by the difluorophosphino-groups were of interest, as predictions about these had been made on the basis of n.m.r. coupling constants.¹²

ments of the structure of $N(PF_2)(SiH_3)_2$ it was assumed that the $N(PF_2)$ group had local C_s symmetry, and that the two $N(SiH_3)$ groups had local C_{3v} symmetry. The $N(SiH_3)_2$ group was assumed to have C_2 symmetry, with the two SiH_3 groups twisted away from the conformation in which one Si-H bond of each group was *trans* to the further N-Si bond. The $PNSi_2$ group was initially assumed to be planar, with C_{2v} symmetry, but distortions of the P-N bond, both in the plane and perpendicular to it, were subsequently permitted: in the final refinements the distortion in the plane was the only one allowed. Finally, the PF_2 group was

allowed to twist, about the P-N bond, with zero twist angle defined for the conformation in which the FPF angle bisector lay in the NSi₂ plane.

With these assumptions, the structure was defined by 11

The conformation adopted by the -PF₂ group was found by fixing the twist angle at various values, and comparing the *R* factors obtained. By coincidence, the radial distribution curves for twist angles of 10 and 80° are extremely

TABLE 2
Least-squares correlation matrix ($\times 100$) for N(PF₂)(SiH₃)₂ *

<i>r</i> ₁	<i>r</i> ₂	<i>r</i> ₃	Angle					<i>u</i> ₂	<i>u</i> ₅	<i>u</i> ₆	<i>u</i> ₁₁	<i>u</i> ₁₄	<i>u</i> ₂₆	<i>k</i> ₁	<i>k</i> ₂	
			1	2	4	5	7									
100	42						56									
	100						69									
		100														
			100	-45	-40									51		
				100					67							
					100				-62							
						100	-57			-55						
							100			-79						
								100								
									100							
										43						
											46	-42	-43			
												46				
													46			
														100		
															100	
																100

* Only elements with absolute values ≥ 40 are included.

geometrical parameters. Although there were strong correlations between parameters (Table 2) caused by overlap of peaks in the radial distribution curve (Figure 1), it was soon clear that the PNSi₂ skeleton was planar, and that the three angles at nitrogen were equal, within experimental error. Most of the other heavy-atom parameters refined

similar but the 10° form gives a significantly lower *R* factor, and other parameters refine to more reasonable values with the larger twist angle. The silyl twist angle was also found by a similar process, but other parameters associated with

TABLE 3
Molecular parameters for N(PF₂)(SiH₃)₂ *

	Distance/pm	Amplitude/pm
(a) Independent distances		
<i>r</i> ₁ (P-F)	158.5(3)	4.7 (fixed)
<i>r</i> ₂ (P-N)	168.0(4)	5.3(5)
<i>r</i> ₃ (Si-N)	175.5(4)	5.3 (tied to <i>u</i> ₂)
<i>r</i> ₄ (Si-H)	149.0 (fixed)	8.8 (fixed)
(b) Dependent distances		
<i>d</i> ₅ (F...N)	249.1(12)	10.8(11)
<i>d</i> ₆ (F...Si)	407.3(15)	11.3(12)
<i>d</i> ₇ (F...Si)	385.4(21)	11.3 (tied to <i>u</i> ₆)
<i>d</i> ₈ (F...Si)	295.7(22)	11.3 (tied to <i>u</i> ₆)
<i>d</i> ₉ (F...Si)	324.0(19)	11.3 (tied to <i>u</i> ₆)
<i>d</i> ₁₀ (F...F)	237.3(18)	10.8 (tied to <i>u</i> ₅)
<i>d</i> ₁₁ (Si...Si)	304.0(25)	10.1(6)
<i>d</i> ₁₂ (Si...P)	296.7(13)	10.1 (tied to <i>u</i> ₁₁)
<i>d</i> ₁₃ (Si...P)	298.1(23)	10.1 (tied to <i>u</i> ₁₁)
<i>d</i> ₁₄₋₂₅ (F...H)	255.5-514.7	11.1(39)
<i>d</i> ₂₆₋₂₈ (P...H)	309.9-402.2	11.9(39)
<i>d</i> ₂₉ (N...H)	266.2(15)	12.0 (fixed)
<i>d</i> ₃₀₋₃₂ (Si...H)	339.5-428.4	11.9 (tied to <i>u</i> ₂₆)
<i>d</i> ₃₃ (H...H)	242.5 (fixed)	12.0 (fixed)
<i>d</i> ₃₄₋₃₉ (H...H)	296.7-530.8	20.0 (fixed)
(c) Independent angles/°		
Angle 1 (F-P-F)		96.9(10)
Angle 2 (F-P-N)		99.4(7)
Angle 3 (N-Si-H)		110 (fixed)
Angle 4 (Si-N-Si)		120.0(15)
Angle 5 (P-N in plane def.)		0.5(9)
Angle 6 (SiH ₃ twist)		8 (fixed)
Angle 7 (PF ₂ twist)		14.0 (12)

* All distances are *r*_a.

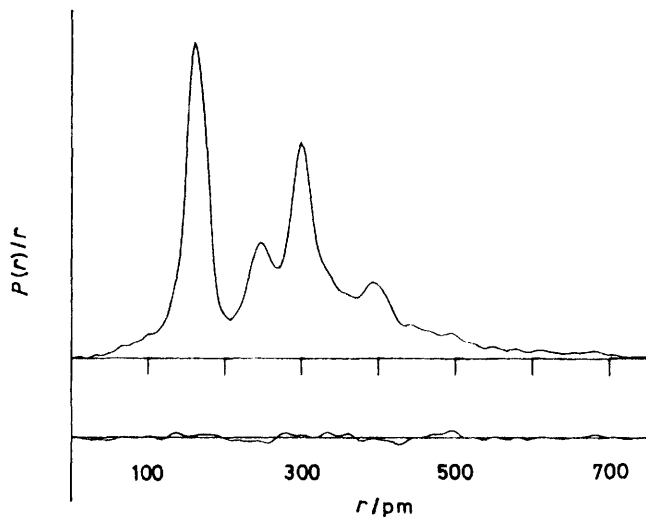


FIGURE 1 Observed and difference radial distribution curves, $P(r)/r$, for N(PF₂)(SiH₃)₂. Before Fourier inversion the data were multiplied by $s \cdot \exp[-0.000\ 015\ s^2/(Z_p - f_p)(Z_r - f_r)]$

easily, but the three bonded distances P-F, P-N, and Si-N were strongly correlated, and occasionally the relative positions of the P-F and P-N distances would reverse. On the basis of known bond lengths in other difluorophosphinamines^{4,5,8,11,17} the ratio $r(\text{P-N}) : r(\text{P-F})$ was assumed to be $1.060 \pm 0.002 : 1$, and this 'predicate observation'¹⁸ was used as an additional experimental datum in subsequent refinements. Similarly, the ratio $\text{F-P-N} : \text{F-P-F}$ was taken to be $1.035 \pm 0.015 : 1$, and this mild constraint was sufficient to stabilise the refinements.

hydrogen-atom positions could not be refined, and were fixed at reasonable values.

The results of the final refinement, for which *R*_G was 0.08 and *R*_D was 0.06, are given in Table 3. Errors quoted are

estimated standard deviations obtained in the least-squares analysis, increased to allow for systematic errors. The observed and final weighted difference molecular scattering intensities are shown in Figure 2. The structure of the molecule is shown in Figure 3(a).

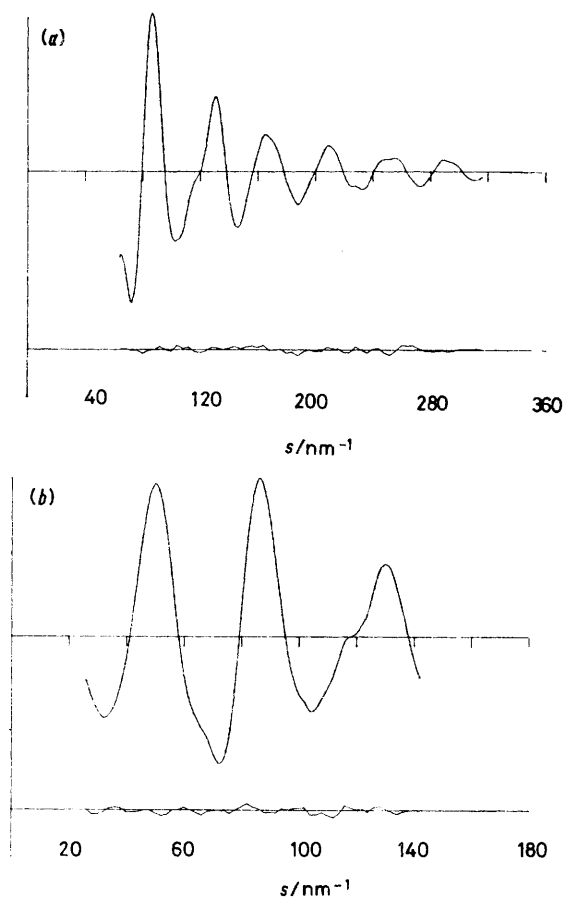


FIGURE 2 Observed and final weighted difference molecular scattering intensities for $N(PF_2)(SiH_3)_2$ at nozzle-to-plate distances of (a) 128 and (b) 284 nm

Bis(difluorophosphino)silylamine.—In the molecular model used for the refinements of this structure, it was assumed that the two $N(PF_2)$ groups were identical, and had C_s symmetry, that the $N(SiH_3)$ group had C_{3v} local

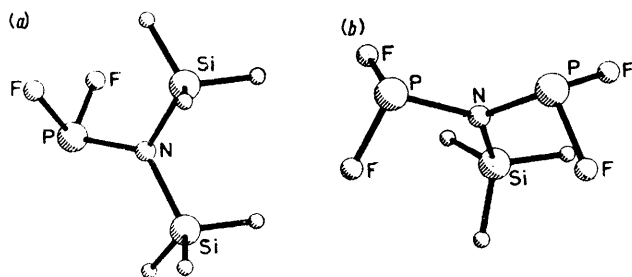


FIGURE 3 Molecular structures of (a) $N(PF_2)(SiH_3)_2$ and (b) $N(PF_2)_2(SiH_3)$

symmetry, and that the P_2NSi skeleton had C_s symmetry. It was soon apparent that the bonds to nitrogen were coplanar, and in the later refinements this was assumed, with a single angle (PNP) describing the co-ordination at nitrogen.

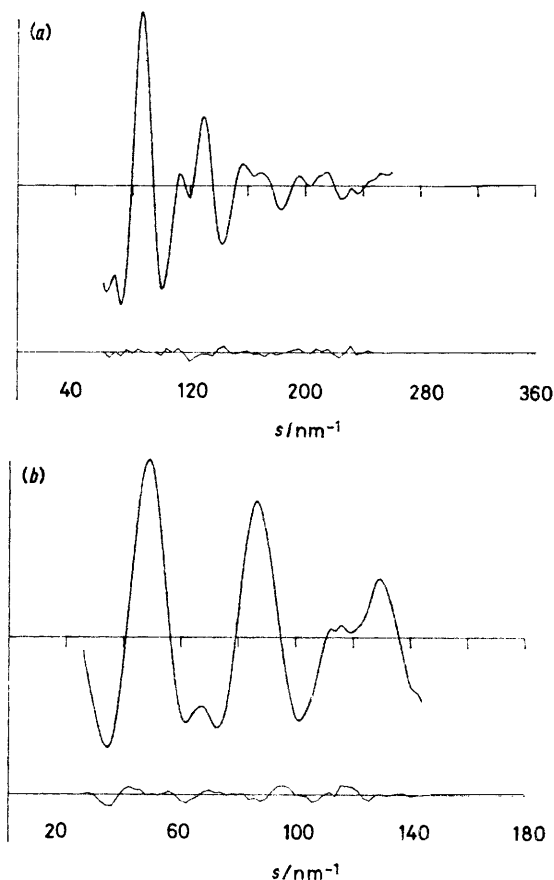


FIGURE 4 Observed and final weighted difference molecular scattering intensities for $N(PF_2)_2(SiH_3)$ at nozzle-to-plate distances of (a) 128 and (b) 285 nm

The conformation was described by three angles. The SiH_3 twist angle was taken to be zero when one $Si-H$ bond lay in the skeletal plane. The two PF_2 twist angles were defined to be zero when the FPF angle bisectors lay *cis*

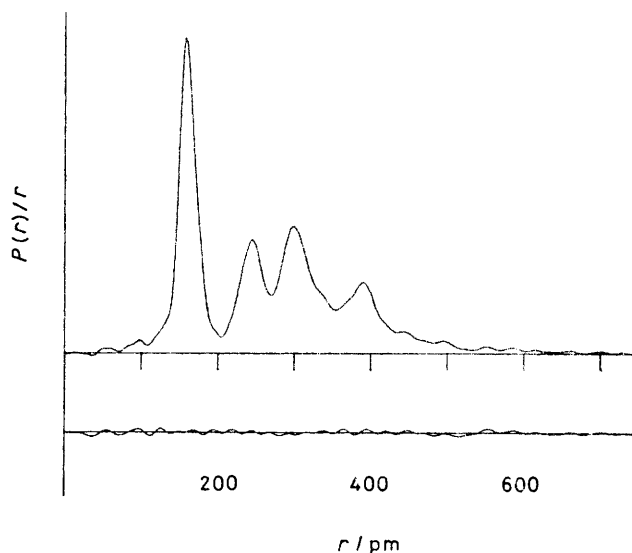


FIGURE 5 Observed and difference radial distribution curves, $P(r)/r$, for $N(PF_2)_2(SiH_3)$. Before Fourier inversion the data were multiplied by $s \cdot \exp[-0.000015 s^2/(Z_p - f_p)(Z_F - f_F)]$

to the N-Si bond. These two angles could be constrained to be equal, or equal and opposite, giving C_2 or C_s symmetry to the $N(PF_2)_2Si$ unit, or they could be varied independently.

TABLE 4
Molecular parameters for $N(PF_2)_2(SiH_3)$ *

	Distance/pm	Amplitude/pm
(a) Independent distances		
r_1 (P-F)	157.0(2)	4.7(3)
r_2 (P-N)	169.1(4)	5.2 (tied to u_1)
r_3 (Si-N)	176.7(7)	5.2 (tied to u_1)
r_4 (Si-H)	145.8(30)	8.8 (fixed)
(b) Dependent distances		
d_5 (N...F)	248.7(5)	8.1(8)
d_6 (F...F)	233.5(8)	8.1 (tied to u_5)
d_7 (F...F)	496.5(8)	21.2(25)
d_8 (F...F)	431.2(7)	21.2 (tied to u_7)
d_9 (F...F)	445.2(7)	21.2 (tied to u_7)
d_{10} (F...Si)	316.2(31)	25.6(25)
d_{11} (F...Si)	309.6(30)	25.6 (tied to u_{10})
d_{12} (P...Si)	301.2(6)	11.5(7)
d_{13} (P...F)	386.5(24)	14.0(7)
d_{14} (P...F)	391.8(21)	14.0 (tied to u_{13})
d_{15} (P...P)	289.3(11)	11.5 (tied to u_{12})
d_{16-27} (F...H)	260.5—455.8	22 (fixed)
d_{28} (H...H)	237.3(50)	18 (fixed)
d_{29-31} (P...H)	328.6—419.0	18 (fixed)
d_{32} (N...H)	264.7(21)	15 (fixed)
(c) Independent angles/°		
Angle 1 (F-P-F)		96.1(5)
Angle 2 (F-P-N)		99.3(3)
Angle 3 (P-N-P)		117.6(7)
Angle 4 (N-Si-H)		110 (fixed)
Angle 5 (PF_2 twist)		-3.3(27)
Angle 6 (SiH_3 twist)		50 (fixed)

* All distances are r_2 .

Of the 11 geometrical parameters, only the $NSiH$ and the SiH_3 twist angles could not be refined. The latter was fixed at 50° , the value giving the lowest R factor in a series

correlation matrix is given in Table 5. The intensity data are shown in Figure 4, and the radial distribution curve in Figure 5. The molecular structure is shown in Figure 3(b).

DISCUSSION

The gas-phase structures of $N(PF_2)(SiH_3)_2$ and $N(PF_2)_2(SiH_3)$ in both cases reveal an entirely planar arrangement of ligands around nitrogen. The absence of any apparent shrinkage due to out-of-plane deformations of the NR_3 group may be attributed to the fact that the atoms bound to nitrogen in all cases contact each other at distances approximating to the sums of their Bartell hard-sphere radii,¹⁹ precluding closer approach.

The angles at nitrogen are 120° within experimental error in the case of $N(PF_2)(SiH_3)_2$. A slight narrowing of the PNP angle in $N(PF_2)_2(SiH_3)$ from 120° [$118.2(10)^\circ$] may be due to the absence of steric crowding between neighbouring PF_2 groups, since the fluorines tend to point away from each other in the preferred conformation.

In both molecules $r(Si-H)$ was fixed at a reasonable value and $r(P-F)$ refined to a value consistent with those expected for the F_2PN moiety, as shown in Table 6. Since some π character can be assigned to the R-N bonds, which are in all cases shorter than those expected for a corresponding single bond, some interest lay in investigating the effect of PF_2 and silyl groups competing for the lone pair on nitrogen. It was found that while the P-N bond lengths for the mono and bis PF_2 species, being 168.0(4) pm and 169.1(4) pm respectively, were substantially shorter than those found in $N(PF_2)_3$ [171.1(4) pm],⁴ the Si-N bond lengths in both cases were some 2–3 pm longer than that measured in trisilylamine (Table 6). This clearly demonstrates that the PF_2 group

TABLE 5
Least-squares correlation matrix ($\times 100$) for $N(PF_2)_2(SiH_3)$ *

r_1	r_2	r_3	r_4	Angle				u_1	u_5	u_7	u_{10}	u_{12}	u_{13}	k_1	k_2		
				1	2	3	5										
100		51						40									r_1
	100	-43															r_2
		100															r_3
			100														r_4
				100													1
					100				66								2
						100			-35								3
							100										5
								100									u_1
									100								u_5
										100							u_7
											100						u_{10}
												100					u_{12}
													100				u_{13}
														100			k_1
															100		k_2

* Only elements with absolute values ≥ 40 are included.

of test refinements. The PF_2 twist angles were varied over a wide range, but the lowest R factors were obtained when both angles were close to zero; a small C_s distortion was preferred to a C_2 distortion.

The results of the final refinement, for which R_G was 0.06 and R_D was 0.04, are listed in Table 4, and the least-squares

has a greater propensity for accepting electron density from the p orbital on nitrogen than the silyl group, and this is almost certainly due to the electron-withdrawing effect of the fluorines bonded to phosphorus. It has been shown that replacing hydrogens with fluorines on silyl groups bound to nitrogen shortens the Si-N bond,

from 171.5 pm in $\text{NMe}_2(\text{SiH}_3)$ ¹⁰ to 165 pm in $\text{NMe}_2(\text{SiF}_3)$.²⁰ We hope soon to undertake a gas-phase study of the molecular $\text{NH}(\text{PMe}_2)_2$ which may therefore be expected to have P-N bonds substantially longer than those found for $\text{NH}(\text{PF}_2)_2$.

The angles at phosphorus require no special comment:

analysis of the last molecule. In $\text{N}(\text{PF}_2)(\text{SiH}_3)_2$ the FPF bisector was found to lie 14° away from the skeletal plane, corresponding to a substantially larger torsional vibration than that found for $\text{N}(\text{PF}_2)_2(\text{SiH}_3)$.

In both molecules studied here, attractive $\text{H} \cdots \text{F}$ interactions almost certainly play the major part in

TABLE 6
Geometric parameters for some difluorophosphino- and silyl-amines

Compound	Distances/pm			Angles/°	
	r(P-F)	r(P-N)	r(Si-N)	FPF	FPN
$\text{N}(\text{PF}_2)_3$ ^a	157.4(2)	171.1(4)		96.9(3)	99.2(3)
$\text{N}(\text{PF}_2)_2(\text{SiH}_3)$ ^b	157.0(2)	169.1(4)	176.7(7)	96.1(5)	99.3(3)
$\text{N}(\text{PF}_2)(\text{SiH}_3)_2$ ^b	158.7(3)	168.0(4)	175.5(4)	96.9(10)	99.4(7)
$\text{N}(\text{SiH}_3)_3$ ^c			173.4(2)		
$\text{NH}(\text{PF}_2)_2$ ^d	158.4(3)	168.4(8)		95.6(10)	98.3(7)
$\text{NH}(\text{PF}_2)(\text{SiH}_3)$ ^e	157.5(3)	165.4(6)	172.4(7)	101.6(12) ^f	95.2 ^f
$\text{NH}(\text{SiH}_3)_2$ ^g			172.5(3)		

^a Ref. 4. ^b This work. ^c Ref. 2. ^d Ref. 5. ^e Ref. 11. ^f See text. ^g Ref. 3.

FPF and FPN in both cases give expected values for the F_2PN group (Table 6). Typical values for these parameters range from 95–97° and 98–100° respectively. In the case of $\text{NH}(\text{PF}_2)(\text{SiH}_3)$ it may be that these strongly correlated angles have been reversed in the refinements.

The conformation of the PF_2 groups in PF_2 amines is generally of some interest, since they can be directed by two factors: lone-pair repulsions between P and P or P and N; and attractive interactions between F and H, the latter being important for all NR_3 compounds ($\text{R} = \text{PF}_2, \text{SiH}_3, \text{CH}_3$, or H) containing PF_2 groups, except $\text{N}(\text{PF}_2)_3$. In general fluorine-hydrogen interactions predominate over lone-pair repulsions, as is evident in the cases of $\text{NMe}(\text{PF}_2)_2$ ²¹ and $\text{NH}(\text{PF}_2)_2$ ⁵ where attractive $\text{H} \cdots \text{F}$ interactions force the phosphorus lone pairs, although orthogonal to that on nitrogen, to lie *cis* to each other in the major conformer for each molecule. For $\text{N}(\text{PF}_2)_2(\text{SiH}_3)$ and $\text{N}(\text{PF}_2)(\text{SiH}_3)_2$ n.m.r. studies had already been used to predict the likely orientations of the PF_2 groups.¹² It has been suggested^{22,23} that some two- or three-bond couplings to three-co-ordinate phosphorus are sensitive to conformation, with large couplings resulting from atoms lying *cis* to the lone pair on phosphorus. In $\text{N}(\text{PF}_2)_2(\text{SiH}_3)$ both $^3J(^{31}\text{P}^1\text{H})$ and $^2J(^{31}\text{P}^{29}\text{Si})$ are small (3.5 and 7 Hz respectively), indicating that the FPF bisectors lie *cis* to the silyl group. In $\text{N}(\text{PF}_2)(\text{SiH}_3)_2$ n.m.r. couplings have been explained in terms of the average of one *cis* and one *trans* $J(\text{PX})$ ($\text{X} = ^{29}\text{Si}$ or ^1H), indicating fast rotation of the PF_2 group on the n.m.r. time scale. These predictions have been verified by the present study.

In $\text{N}(\text{PF}_2)_2(\text{SiH}_3)$ the PF_2 torsions refined as a single parameter, with the best fit being for a conformation where the $\text{N}(\text{PF}_2)_2$ group adopts a local C_s symmetry with the FPF angle bisectors lying 3° away from being *cis* to the Si-N bond. This result is identical in principle to those found for $\text{NH}(\text{PF}_2)_2$ and $\text{NMe}(\text{PF}_2)_2$, and a similar situation has been predicted for $\text{N}(\text{GeH}_3)(\text{PF}_2)_2$.²² We are at present undertaking a gas-phase structural

determining the conformations of the PF_2 groups. $\text{N}(\text{PF}_2)(\text{SiH}_3)_2$ contains $\text{H} \cdots \text{F}$ contacts from 255.5 pm and $\text{N}(\text{PF}_2)_2(\text{SiH}_3)$ similar contacts from 260.5 pm. The lower values in both cases correspond to the sum of the van der Waals radii for fluorine and hydrogen, and represent the optimum distance for maximum $\text{H} \cdots \text{F}$ interaction.

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